APPLIED PHYSICS LETTERS VOLUME 84, NUMBER 25 21 JUNE 2004

Size effects in ultrathin epitaxial ferroelectric heterostructures

V. Nagarajan, ^{a)} S. Prasertchoung, T. Zhao, H. Zheng, J. Ouyang, and R. Ramesh ^{b)} *Materials Research Science and Engineering Center, University of Maryland, College Park, Maryland 20742*

W. Tian and X. Q. Pan

Department of Materials Science and Engineering, University of Michigan, Ann Arbor, Michigan 48109

D. M. Kim and C. B. Eom

Department of Materials Science and Engineering, University of Wisconsin-Madison, Madison, Wisconsin 53706

H. Kohlstedt and R. Waser

Institut für Festkörperforschung and CNI, Forschungzentrum Jülich, D-52425 Jülich, Germany

(Received 28 January 2004; accepted 1 May 2004; published online 10 June 2004)

In this letter we report on the effect of thickness scaling in model $PbZr_{0.2}Ti_{0.8}O_3(PZT)/SrRuO_3$ heterostructures. Although theoretical models for thickness scaling have been widely reported, direct quantitative experimental data for ultrathin perovskite (<10 nm) films in the presence of real electrodes have still not been reported. In this letter we show a systematic quantitative experimental study of the thickness dependence of switched polarization in (001) epitaxial PZT films, 4 to 80 nm thick. A preliminary model based on a modified Landau Ginzburg approach suggests that the nature of the electrostatics at the ferroelectric–electrode interface plays a significant role in the scaling of ferroelectric thin films. © 2004 American Institute of Physics.

[DOI: 10.1063/1.1765742]

The effect of thickness scaling in ferroelectrics has recently been of immense interest. ¹⁻¹² As the dimensions (both lateral and vertical direction) of the perovskite layer decreases, the fundamental question of size dependence becomes crucial. From a theoretical point of view, two models have been traditionally used to describe size effects, namely an "intrinsic" effect ^{9,10,13} and a "depoling field" effect. ^{4,5,14,15} Experimentally Tybell *et al.*⁸ qualitatively showed that even a 4-nm-thick epitaxial PbZr_{0.2}Ti_{0.8}O₃ (PZT) film on Nb:STO is ferroelectric. However a direct experimental quantification of the ferroelectric polarization, particularly for films in the sub-10 nm thickness range has not been reported. For such ultrathin films direct experimental quantification of size effects are complicated by extrinsic effects such as leakage and therefore methods other than the traditional P-E hysteresis loop have been reported to characterize the stability of the polar state.^{1,7} This letter presents experimental measurements of the switched polarization in PZT films of thickness down to 4 nm, in the presence of real electrodes.

A 70-nm-thick SRO layer was grown on STO at 650 °C followed by the PZT layer via pulsed laser deposition. The deposition was carried out at 100 mTorr of oxygen and the sample was cooled down from growth temperature 1 atm of oxygen. In order to avoid complications from 90° domain formation the PZT films were grown in a thickness range from 4 to 80 nm, for which they are entirely c-axis oriented. The switchable polarization was measured using a Radiant Technologies Precision Premier system at 16 kHz (hysteresis loops) and an AFM based pulsed probing technique with conductive Pt–Ir tips was employed to measure the pulsed polarization. 16

We focused on the PZT (0/20/80) composition, since it has an in-plane lattice parameter of 3.94 Å, ¹⁷ which is closely lattice matched to SRO(3.93 Å). Figure 1(a) is a low magnification TEM image of a 4 nm (nominal) thick film; the interfaces between SRO and PZT are sharp, identified as dashed lines in the high resolution image, Fig. 1(b). The electrode–ferroelectric interface shows a significantly reduced dislocation density, attributed to the small lattice mismatch (0.7%) at growth temperature of 600 °C. The inset to Fig. 1(b) is a selected area optical diffraction of the high-resolution image, which yields a quantitative tetragonality of 1.05



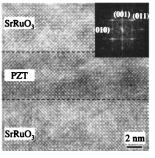


FIG. 1. Structural characterization of ultrathin PbZr_{0.2}Ti_{0.8}O₃ films with high resolution transmission electron microscopy (HRTEM). (a) Cross-section TEM of 4 nm PZT film with top and bottom SrRuO₃ (SRO) layers grown on SrTiO₃ (STO). The image shows that the 4 nm PZT layer is continuous over several microns length. (b) HRTEM of the same sample. It shows the interfaces are sharp and clean, without misfit dislocations. Inset shows selected area optical diffraction obtained from the HRTEM image.

a)Electronic mail: valanoor@iwe.rwth-aachen.de

b)Present address: Department of Materials Science and Engineering, University of California, Berkeley, CA.

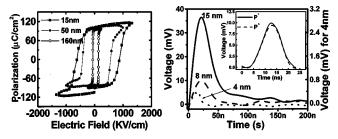


FIG. 2. Ferroelectric measurements as a function of film thickness. (a) Hysteresis loops for 15-, 50-, and 160-nm-thick PZT films. The loops are sharp and well saturated down to 15 nm with $2P_r{\sim}\,150~\mu\text{C/cm}^2$. (b) Current transients for the 15 (solid), 8 (dashed), and 4 nm (dotted) film, respectively, measured with the AFM based pulsed probing technique. The applied field was 2750 kV/cm for the 8- and 15-nm-thick film, while 3250 kV/cm was applied to the 4 nm film. A sharp drop in the signal strength as seen from the vertical scale is observed. The inset shows switched (solid) P^* and non-switched (dashed) P^{\wedge} response for the 4-nm-thick film.

Figure 2(a) is a set of hysteresis loops measured at 16 kHz for 15-, 50-, and 160-nm- (for comparison) thick films. The $2P_r$ value obtained from the loop for the 15-nm-thick film is \sim 150 μ C/cm², which is in agreement with theoretically predicted values for this composition of PZT with an in-plane compressive strain. 10,17,18 Additionally a systematic increase in the coercive field is observed as the thickness is scaled down to 15 nm, in agreement with previous reports. 1,2,19 However for sub-10-nm-thick films the hysteresis loops were leaky, and not credible. Therefore we measured the polarization under pulsed probing conditions using an AFM based test setup. 16 In order to reduce short circuit paths and to allow fast rise times, capacitors with submicron lateral dimensions were fabricated using a modified lift-off technique in which the photoresist was deliberately underdeveloped. By making contact to 0.4 by 0.4 μ m² pads, we recorded the switched (P^*) and nonswitched polarization (P^{\wedge}) to obtain the switchable polarization (ΔP) . Figure 2(b) plots the switching transients of the 15 and 8 nm at an applied field of 2750 kV/cm and transients measured for the 4 nm film at 3250 kV/cm, respectively. The switched charge (i.e., area under the transient) for the 15 and 8 nm films were calculated to be 145 and $70\pm5 \mu C/cm^2$, respectively. A higher field was necessary for the 4 nm film to obtain a fully switched transient. Integration of the ΔP transient, yielded a switched charge of $11\pm3~\mu\text{C/cm}^2$. This is also evident in the change of the vertical scale in the signal response recorded by the oscilloscope. For the 15 nm film it is approximately 40 mV (left axis) while for the 4 nm film it has dropped to 0.5 mV (right axis). The inset to Fig. 2(b) is a plot of the P^* and P^{\wedge} transients for the 4 nm film. The difference between the P^* and P^{\wedge} is minute, indicative of a very low magnitude of the switched charge. These results demonstrate that down to 15 nm there is no observable drop in the switched polarization. Below 15 nm, it progressively decreases to approximately 11 μ C/cm² for the 4 nm film.

We now compare the experimentally measured thickness dependence with that predicted from theory. In Fig. 3 we show the normalized polarization (termed as the order parameter) as a function of film thickness normalized to the correlation length, ξ (d/ξ). The value of ξ for this particular composition was calculated to be 2.4 nm using parameters from Li²⁰ and Zembilgotov.¹⁰ We also plot the predicted thickness dependence, from an intrinsic size effect model^{9,10,20} (solid plot), from the macroscopic depoling field

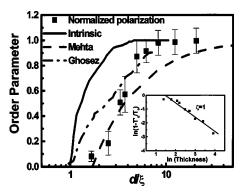


FIG. 3. Comparison of the order parameter as a function of thickness with theoretical predictions. The solid plot shows the predictions from an intrinsic size effect model, the dashed plot from the macroscopic depoling field model and the dotted plot is *ab initio* depoling field calculations for SRO/BTO/SRO by Junquera and Ghosez. The squares are experimentally measured switched polarization normalized to the thick film value. The inset plots the calculated $\ln[(T_C^{\text{film}} - T_C)/T_C]$ vs \ln (thickness) with a linear fit to the calculation, which reveals a slope $\zeta = 1$.

model^{14,15} (dashed plot), and *ab initio* calculations for SRO/BaTiO₃/SRO (dotted plot). The plot shows that the sub-10-nm-thick films lie more closely to the depoling model. However in order to clearly differentiate between the intrinsic size effect and depoling field effect, we need to explore the nature of the critical exponent (*or scaling law*). Using the approach of Kretschmer and Binder¹³ the Curie temperature of the thin film, T_C^{film} , is related to the expected theoretical transition temperature for a film of the same thickness (but without any polarization suppression, T_C), as

$$\frac{T_C^{\text{film}} - T_C}{T_C} \propto d^{-\zeta},\tag{1}$$

where d is the thickness of the film and ζ is the shift exponent, equal to 1 for the case where the suppression is dominated by depolarizing field and $\zeta=2$ for the case where the suppression is dominated by intrinsic effects. The inset to Fig. 3, which plots

$$\ln\left(\frac{T_C^{\text{film}} - T_C}{T_C}\right)$$

as a function of film thickness, is a theoretical prediction of the dependence of T_C using an elementary model based on the Landau–Ginzburg–Devonshire (LGD) equation. We have used the formalism of Pertsev *et al.*¹⁰ to modify prefactors in the

$$\alpha' = \alpha - \frac{2Q_{12}\varepsilon_M}{S_{11} + S_{12}},\tag{2}$$

$$\beta' = \beta + \frac{4Q_{12}^2}{S_{11} + S_{12}},\tag{3}$$

$$\gamma' = \gamma, \tag{4}$$

where ε_M is the misfit strain, S_{ij} is the compliance along the respective crystallographic directions, and Q_{12} is the electrostriction coefficient. To extract T_C^{film} , we used the Curie–Weiss law and the above modified LGD equations, which correlate the measured polarization to the transition temperature. Our preliminary calculations show a linear fit with a slope of ~ 1 , suggesting the governing role of depoling fields

at the electrode–ferroelectric interface in determining the stability of ferroelectricity, in agreement with the theoretical predictions of Ghosez⁵ and Glinchuk.⁴ However to conclusively verify this, accurate experimental determination of T_C for a ferroelectric heterostructure with top and bottom electrodes, coupled with a more complex model which takes into account the surface and/or depolarization effects, ^{9,10} is needed. Such experiments on the direct experimental determination of T_C and the corresponding calculations are ongoing.

This work was supported by NSF MRSEC Contract No. 00-80008 and a NSF US-Europe collaborative Grant No. DMR 02-44288. The work at University of Wisconsin is supported by the NSF under Contract No. DMR-9973801. V.N. acknowledges the Alexander von Humboldt foundation for his stay in FZ-Juelich, Germany. We wish to thank S. Streiffer and Ph. Ghosez for fruitful discussions and critical reading of the manuscript.

- ⁶T. M. Shaw, S.-T. McKinstry, and P. C. McIntyre, Annu. Rev. Mater. Sci. 30, 263 (2000).
- ⁷S. K. Streiffer, J. A. Eastman, D. D. Fong, C. Thompson, A. Munkholm, M. V. R. Murty, O. Auciello, G. R. Bai, and G. B. Stephensonl, Phys. Rev. Lett. **89**, 067601 (2002).
- ⁸T. Tybell, C. H. Ahn, and J.-M. Triscone, Appl. Phys. Lett. **75**, 856 (1999)
- ⁹W. L. Zhong, B. D. Qu, P. L. Zhang, and Y. G. Wang, Phys. Rev. B 50, 12375 (1994).
- ¹⁰A. G. Zembilgotov, N. A. Pertsev, H. Kohlstedt, and R. Waser, J. Appl. Phys. 91, 2247 (2002).
- ¹¹C. L. Wang, Y. Xin, X. S. Wang, and W. L. Zhong, Phys. Rev. B 62, 11423 (2000).
- ¹²N. Yanase, K. Abe, N. Fukushima, and T. Kawakubo, Jpn. J. Appl. Phys., Part 1 38, 5305 (1999).
- ¹³R. Kretschmer and K. Binder, Phys. Rev. B **20**, 1065 (1979).
- ¹⁴I. P. Batra, P. Wurfel, and B. D. Silverman, J. Vac. Sci. Technol. **10**, 687 (1973).
- ¹⁵R. R. Mehta, B. D. Silverman, and J. T. Jacobs, J. Appl. Phys. **44**, 3379 (1973).
- ¹⁶S. Prasertchoung, V. Nagarajan, Z. Ma, R. Ramesh, J. S. Cross, and M. Tsukada, Appl. Phys. Lett. **84**, 3130 (2003).
- ¹⁷Landolt-Börnstein, Numerical Data and Functional Relationships in Science and Technology, Vol. 16, edited by K.-H. Hellwege and A. M. Hellwege (Springer, Berlin, 1981).
- ¹⁸M. J. Haun, E. Furman, S. J. Jang, and L. E. Cross, Ferroelectrics 99, 45 (1989).
- ¹⁹N. A. Pertsev, J. R. Contreras, V. G. Kukhar, B. Hermanns, H. Kohlstedt, and R. Waser, Appl. Phys. Lett. 83, 3356 (2003).
- ²⁰S. Li, J. A. Eastman, J. M. Vetrone, C. M. Foster, R. E. Newnham, and L. E. Cross, Jpn. J. Appl. Phys., Part 1 36, 5169 (1997).

 ¹A. V. Bune, V. M. Fridkin, S. Ducharme, L. M. Blinov, S. P. Palto, A. V. Sorokin, S. G. Yudin, and A. Zlatkin, Nature (London) 391, 874 (1998).
 ²M. Dawber, P. Chandra, P. B. Littlewood, and J. F. Scott, J. Phys.: Condens. Matter 15, L393 (2003).

³P. Ghosez and K. M. Rabe, Appl. Phys. Lett. **76**, 2767 (2000).

⁴M. D. Glinchuk, E. A. Eliseev, and V. A. Stephanovich, Physica B **322**, 356 (2002).

⁵J. Junquera and P. Ghosez, Nature (London) **422**, 506 (2003).